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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/957,422	09/20/2001	Takayuki Fujioka	9792909-5242	2711
26263 SONNENSCH	7590 12/14/2007 EIN NATH & ROSENTH	EXAMINER		
P.O. BOX 0610	080	BRIGGS, NATHANAEL R		
WACKER DR CHICAGO, IL	IVE STATION, SEARS 7 60606-1080	TOWER	ART UNIT	PAPER NUMBER
011101100,12	00000 1000		2871	
			MAIL DATE	DELIVERY MODE
			12/14/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		<b>2</b> /2				
	Application No.	Applicant(s)				
Office Action Summary	09/957,422	FUJIOKA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Nathanael R. Briggs	2871				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with th	e correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period or Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATI 36(a). In no event, however, may a reply be will apply and will expire SIX (6) MONTHS fi e, cause the application to become ABANDO	ON.  e timely filed  rom the mailing date of this communication.  DNED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 19 S	eptember 2007.					
2a)⊠ This action is <b>FINAL</b> . 2b)□ This	s action is non-final.					
3) Since this application is in condition for allowa	ince this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11,	453 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1,2 and 4-6</u> is/are pending in the app	lication.					
4a) Of the above claim(s) is/are withdra	wn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1,2 and 4-6</u> is/are rejected.	·					
7) Claim(s) is/are objected to.		•				
8) Claim(s) are subject to restriction and/c	or election requirement.					
Application Papers						
9) The specification is objected to by the Examine	er.					
10) The drawing(s) filed on is/are: a) acc	epted or b) objected to by the	ne Examiner.				
Applicant may not request that any objection to the	drawing(s) be held in abeyance.	See 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correc	*					
11) ☐ The oath or declaration is objected to by the Ex	xaminer. Note the attached Off	ice Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119	)(a)-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None of:	, p. 10.10, a. 10.01					
1. Certified copies of the priority document	ts have been received.					
2. Certified copies of the priority document	ts have been received in Applic	eation No				
<ol><li>Copies of the certified copies of the prior</li></ol>	rity documents have been rece	eived in this National Stage				
application from the International Burea	u (PCT Rule 17.2(a)).					
* See the attached detailed Office action for a list	of the certified copies not rece	eived.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summ	arv (PTO-413)				
2) Dotice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Ma	il Date				
Information Disclosure Statement(s) (PTO/SB/08)     Paper No(s)/Mail Date	5)  Notice of Inform 6) Other:	al Patent Application				
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## **DETAILED ACTION**

## Response to Arguments

1. Applicant's arguments with respect to claims 1-2 and 4-6 have been considered but are most in view of the new ground(s) of rejection.

## Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-2 and 4-6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsuda et al. (US 5,936,688) in view of Nakamura et al. (US 5,847,789), and in further view of Itoh et al. (US 6,094,252).
- 4. Regarding claim 1, Tsuda discloses a method of manufacturing a diffusing reflector (see figures 2A-E and 5A-H, for instance) having processes of preparing a substrate (31); forming a first resin film having photosensitivity (32a) on said substrate (31); providing gathering of pillar-shaped bodies (32b) isolated from each other through patterning (33) of said resin film (32a) with the photolithography; deforming gently (32c) said pillar-shaped bodies (32b) through a reflow (column 10, lines 8-11); forming an uneven surface layer (37) having the maximum inclination angle of under 12° (see Fig. 2B) by coating said gently deformed pillar-shaped bodies (32c) and covering with a second resin (34a) open flat spaces (34a) located between said isolated pillar-shaped bodies (32b), thereby minimizing an occurrence of a flat surface area on said substrate

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(37); and forming a metal film (36) on gathering of said gently deformed uneven surface layer (34c). However, Tsuda does not expressly disclose wherein there is located one concave gap between two adjacent isolated pillar-shaped bodies, or wherein the upper end portions of said two adjacent isolated pillar-shaped bodies are higher than a lower end portion of said one concave gap in the thickness direction of the diffusing reflector.

- 5. Regarding claim 1, Nakamura discloses a method of manufacturing a diffuse reflector (see figures 1 and 2, for instance), includes steps of coating said gently deformed pillar-shaped bodies (4, 5) and covering with a second resin (6) open flat spaces (d3) located between said isolated pillar-shaped bodies (4, 5) to form one concave gap (d3) between two adjacent isolated pillar-shaped bodies (4, 5), thereby minimizing an occurrence of a flat surface area on said substrate (2); and forming a metal film (7) on gathering of said gently deformed uneven surface layer (6).
- 6. It would have been obvious to one of ordinary skill in the art at the time the invention was made to use the step of Nakamura in the method of Tsuda. The motivation for doing so would have been to gain good polarizing performance while obtaining diffusion properties to enhance the display, as taught by Nakamura (column 8, lines 21-27).
- 7. Regarding claim 1, Itoh discloses a method of manufacturing a diffuse reflector (see figure 5F, for instance), wherein the upper end portions of said two adjacent isolated pillar-shaped bodies (7a) are higher than a lower end portion of said one concave gap (low portions of layer 8) in the thickness direction of the diffusing reflector.

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- 8. It would have been obvious to one of ordinary skill in the art at the time the invention was made to use the structure of Itoh in the method of Tsuda in view of Nakamura. The motivation for doing so would have been to realize a high quality LCD capable of conducting a bright display without any effect of parallax, as exemplified by Itoh (column 13, lines 15-18). Claim 1 is therefore unpatentable.
- 9. Regarding claim 2, Tsuda in view of Nakamura and in further view of Itoh discloses a method of manufacturing a diffusing reflector as claimed in claim 1 (see figures 2A-E and 5A-H, for instance), wherein said maximum inclination angle is about 10° (Fig. 2B). Claim 2 is therefore unpatentable.
- 10. Regarding claim 4, Tsuda in view of Nakamura and in further view of Itoh discloses a method of manufacturing a diffusing reflector as claimed in claim 1 (see figures 2A-E and 5A-H, for instance), wherein said reflow process is a heat treatment under the temperature of about 220° C (column 10, lines 12-13). Claim 4 is therefore unpatentable.
- 11. Regarding claim 5, Tsuda in view of Nakamura and in further view of Itoh discloses a method of manufacturing a diffusing reflector as claimed in claim 1 (see figures 2A-E and 5A-H, for instance), wherein gathering of polygonal pillar-shaped bodies (32c; column 17, lines 32-36) isolated each other by the divided patterning of said resin film (34a) by said photolithography is provided. Claim 5 is therefore unpatentable.
- 12. Regarding claim 6, Tsuda in view of Nakamura and in further view of Itoh discloses a method of manufacturing a diffusing reflector as claimed in claim 5 (see

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figures 2A-E and 5A-H, for instance), wherein said resin film (34a) is patterned by the divided patterning means so that size of gap between said polygonal pillar-shaped bodies (32c) isolated each other is almost equal to the minimum resolution of photolithography (column 13, lines 33-40). Claim 6 is therefore unpatentable.

## Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nathanael R. Briggs whose telephone number is (571) 272-8992. The examiner can normally be reached on 9 AM - 5:30 PM Monday through Friday.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Nathanael Briggs 11/29/2007

ANDREW SCHECHTER PRIMARY EXAMINER